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**NONFERROUS METALS INDUSTRY STANDARD OF THE
PEOPLE'S REPUBLIC OF CHINA**

YS/T 1025-2015

**High-purity tungsten and tungsten alloy sputtering target used
in electronic film**

电子薄膜用高纯钨及钨合金溅射靶材

(English Translation)

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What this standard covers

This standard specifies the requirements, test methods, inspection rules and marks, packaging, transportation, storage, order form (contract), etc. of high purity tungsten and tungsten alloy sputtering targets for electronic thin films. This standard applies to electronic thin film with high purity tungsten and tungsten alloy shot target, hereinafter referred to as high-purity tungsten and tungsten alloy target.

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